

The 3rd International Symposium on Recent Progress of Energy and Environmental Photocatalysis (Photocatalysis 3)

November 29 - 30, 2019

Katsushika Campus, Tokyo University of Science, Tokyo

Scope

Photocatalysis 3 will be held in Tokyo, Japan in 2019 and organized by Photocatalysis International Research Center, Tokyo University of Science. This symposium program is designed to enable the material researchers from all over the world to give an opportunity to present and discuss about their recent research topics. This symposium will facilitate the participants to build an international research network between academia, government and industry.

Planned Speaker

Plenary

Akira Fujishima (Tokyo University of Science, Japan)
Antoni W. Morawski
(West Pomeranian University of Technology, Poland)
Hongbing Fu (Capital Normal University, China)
Lei Jiang (Chinese Academy of Sciences, China)
Zhongfan Liu (Peking University, China)
Zhongze Gu (Southeast University, China)

Keynote

Qingbo Meng (Chinese Academy of Sciences, China)
Seong-Ju Hwang (Yonsei University, Korea)

Invited

Akihiko Kudo (Tokyo University of Science, Japan)
Akira Nakajima (Tokyo Institute of Technology, Japan)
Antonio Guerrero (Universitat Jaume I, Spain)
Bunsho Ohtani (Hokkaido University, Japan)
Hiroshi Irie (University of Yamanashi, Japan)
Jinfang Zhi (Chinese Academy of Sciences, China)
Jinhua Ye (National Institute for Materials Science, Japan)
Liming Zhang (Fudan University, China)
Masahiro Miyauchi (Tokyo Institute of Technology, Japan)
Masakazu Sugiyama (The University of Tokyo, Japan)
Masanori Sakamoto (Kyoto University, Japan)
Sanjay Latte (Raje Ramrao College, India)
Sudhagar Pitchaimuthu (Swansea University, UK)
Suresh Gosavi (Savitribai Phule Pune University, India)
Teruhisa Ohno (Kyushu Institute of Technology, Japan)
Vicente Rodríguez-González (IPICyT, Mexico)
Xintong Zhang (Northeast Normal University, China)
Weena Siangproh (Srinakharinwirot University, Thailand)
Weiping Qian (Southeast University, China)
Yasuaki Einaga (Keio University, Japan)
Zhi Jiang (Shanghai Jiao Tong University, China)
Zhiliang Wang (The University of Queensland, Australia)

11月29日(金)午後 日本語サブセッション

14:05 - 15:20 光触媒工業会 きれいJAPANプロジェクト サブセッション

岩田広長 氏 (光触媒工業会)
井上友博 氏 (信越化学工業株式会社)
岡山誠史 氏 (ケイミュー株式会社)
福嶋哲弥 氏 (TOTO株式会社)
阿部和広 氏 (太陽工業株式会社)

15:30 - 16:10 光触媒研究推進拠点 平成30年度 研究成果報告会

Registration

Register from official website.

Register
Now!

Contact Us

Website: <https://photocatalysis3.wixsite.com/home>

Symposium Office: photocatalysis3@rs.tus.ac.jp

Organized by Photocatalysis International Research Center (PIRC), Tokyo University of Science (TUS)

Co-organized by Research Institute for Science and Technology (RIST), TUS

University Research Admission Center (URA), TUS

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